

U.S. DEPARTMENT OF COMMERCE  
PATENT AND TRADEMARK OFFICE

## PATENT WITHDRAWAL NOTICE

DATE WITHDRAWN

4/25/2007

WITHDRAWAL NUMBER

15429

The following application has been **WITHDRAWN** from the

**Tuesday, May 01, 2007** issue.

SERIAL NO.

10/827,449

PATENT NUMBER

7,212,710

DRAWINGS

0

CLASS

385/039.000

TITLE

BEAM HOMOGENIZER, LASER IRRADIATION APPARATUS, AND METHOD FOR  
MANUFACTURING SEMICONDUCTOR DEVICE

NAME AND ADDRESS

TANAKA, KOICHIRO  
Atsugi, Japan

REASON FOR WITHDRAWAL

The application is being withdrawn to allow reopening of prosecution.

APPROVED

/ Mary Louise McAskill, Manager /

Statistical Analysis Division